

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of :
: :
Kai YANG, et al. :
: :
Serial No.: Group Art Unit:
: :
Filed: March 27, 2001 Examiner:
: :
For: STABILIZING FLUORINE ETCHING OF LOW-K MATERIALS

PRELIMINARY AMENDMENT

Commissioner for Patents
Washington, DC 20231

Sir:

Prior to examination of the above-referenced application, please amend the application as follows:

IN THE TITLE:

Please change the title from "DAMASCENE PROCESSING USING DIELECTRIC BARRIER FILMS" to --STABILIZING FLUORINE ETCHING OF LOW-K MATERIALS--.

REMARKS

Entry of this preliminary amendment is respectfully requested.

Respectfully submitted,

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